

How it all started; hardware perspective

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Outline

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 - c. Specifications for SIRIUS, the Brazilian machine
- 3. Conclusion



The BL (Before Libera ©) History

☆ 1972-75: For DCI BPM system in Orsay, I used for the first time the concept of 4 electrodes switched to a single channel. The detector was analog but a 10 µm stability over about 1 hour allowed to bring the four DCI beams into interaction.

 1981 to 2001: 11 more BPM systems designed and built, 6 of them together with Rok.

☆ October 2001: SOLEIL construction is officially approved.



SOLEIL BPM System Specifications

	Closed orbit correction	Global Feedback	First turns	Turn-by-turn for machine studies
Number of BPMs	120	48	120	120
measurement resolution (mms)	< 0.2 µmin 1 second	< 0.2 µm (residual on beam with 100 Hz feedback BW)	< 500 µmin a single measurement	< 1 µm in 60 seconds
Absolute accuracy with respect to quad	< 200 µm	×	< 500 µm	< 200 µm
Absolute accuracy after beam based alignment	< 50 µm	×	×	×
Measurement rate	> 1 per second	~ 1 KHz for 100 Hz feedback BW	1 per second	every 60s
Dynamic range	M: 200 \rightarrow 600 mA T: 20 \rightarrow 120 mA	M: 200 \rightarrow 600 mA T: 20 \rightarrow 120 mA	$0.4 \rightarrow 4 \text{ mA}$	$4 \rightarrow 100 \text{ mA}$
Current dependence within a 10 dB range	< 5 µm (< 1µm after calibration)	< 5 µm (< 1µm after calibration)	< 500 µm	×
8-h and 1-month drift at constant current	< 1 µm in 8 h < 3 µm in 1 month	< 1 µmin 8 h < 3 µm in 1 month	< 500 µm	×
Reproducibility versus bunch pattern	< 10 µm (< 1µm after calibration)	< 10 µm (< 1µm after calibration)	< 500 µm	< 500 µm



Guiding Concepts

- Four Electrodes switched to 1 channel: Old DCI concept is the best for photon delivery, but not OK for turn-by-turn measurements required by machine physicists.
- Brain storming session in Orsay (mid 2002): J. Darpentiny proposed 4 electrodes switched to 4 channels. That combines the high stability switching scheme for photon delivery and turn by turn capability for machine physics studies.
- \Leftrightarrow Digital electronics developed for SLS is better than the previous analog ones
- Reliability: for a MTBF (Mean Time Between Failures) better than 3 months on the global feedback system with 120 BPMs, one needs an individual MTBF better than <u>30 years</u> on each BPM (that actually scared us!)



The actors: SOLEIL in France





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The actors: IT in Slovenia



Rok Ursic



Andrej Kosicek





Mojca Franceskin



Uros Mavric





Borut Repic Instrumentation Technologies Libera Workshop







Borut Solar

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Some Development Steps

- European tender procedure ended up with only Instrumentation Technologies having good chances to meet the specifications.
- Design Review at SOLEIL
 - Guenther Rhem from Diamond was invited
 - ➢ July 2003: Diamond chose the Libera for their BPM system
- ☆ March 2004: Prototype acceptance tests in Nova Gorica (SOLEIL + IT)
 - A near 2-year cycle of weekly phone conferences (SOLEIL & IT) with written report started in March 2004. Andrej for IT, JC, Ludo, Nicolas H. and Dominique for SOLEIL.
- December 2004: Booster Commissioning SOLEIL with Andrej & Peter from IT.
- ☆ May 2006 storage Ring commissioning with Andrej & ? Form IT.
- The BPM system (1st turn capability) was the major diagnostic for storing the beam in a very short time.
- ☆ A lot of work remained in 2006, especially to commission the interlock feature.



The actors: Diamond in UK



Michael Abbott



Guenther



Isa Uzun



James Rowland



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2007-2013: Following versions of Libera

Libera Brillance: actually achieved the submicron stability
 Libera Photon extended fast orbit feedback capability to photon BPMs

+ many new members join the Libera family



2013-2020: Future Light Sources, Ultimate Storage Rings (USR)

New 3rd generation light sources with very low emittance are in contruction: NSLSII (Brookhaven, USA), MAXIV (Lund, Sweden), SIRIUS (Campinas, Brazil) or nearly funded: BAPS (Beijing, China)

Photon beam emittance ε = source point size * divergence Diffraction limit of 10 keV photons corrresponds to ε =10 pm.rad

Emittance H in pm.rad~40002000 to 500320280~10	Machine	ESRF, SOLEIL	NSLS II	MAX IV	SIRIUS	BAPS
	Emittance H in pm.rad	~4000	2000 to 500	320	280	~10



Size and Divergence limits of 10 keV Photon Beam from a 2m undulator



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Stability Requirements of BPMs & Electronics

◇ Orbit Feedback locks the beam on the BPM center
 ◇ Beam stability cannot be better than BPM stability
 ◇ BPM stability requirements are usually:
 > beam position stability better than photon beam size /10
 > beam angle stability better than photon beam divergence / 10
 We need numbers:
 ◇ Let's take the smallest source point size and divergence of 10
 keV photons out of a 2 m long undulator
 Divergence = 5.6 µrad

Size $\approx 3.6 \,\mu m$



Beam Position & Angle Stability Requirements for Sirius, the Brazilian New Machine

 \Leftrightarrow Standard requirements of 1/10 beam size and divergence in

 \succ for undulator length = 2 m

vertical plane: size and div. = 10 keV diffraction limit

 $\sigma_y / 10 \approx 360 \text{ nm}$ $\sigma_y ' / 10 \approx 560 \text{ nrad}$

Angular resolution of a pair of BPMs = SQRT(2)* σ_{BPM} / BPM separation Then, $\sigma_{BPM} \leq$ BPM separation /SQRT(2)

Then <u>vertical BPM resolution < 360 nm</u>

Horizontal plane: Electron beam size and divergence are dominant

 $\sigma_x/10\approx 3\;\mu m$

 $\sigma_x{\,}'/10\approx 0.4~\mu rad$ requires ~1 μm resolution for a 3 m BPM separation

Then Horizontal BPM resolution $< 1 \mu m$





Example of short term stability (SOLEIL)





Special Invar BPM and XBPM Stands for two long Beamlines: Anatomix and NanoScopium

- 4 Invar <u>BPM stands and cradles for</u> Reliable measurements of long term beam stability (at each end of the two undulators)
- 1 XBPM and its stand in Invar on NanoScopium Frontend (FMB design with Invar vacuum chamber).
- XBPM came in operation last
 October, but a local stability problem
 prevented evaluation of the machine
 stability based on that key source
 point
- The machine stability evaluation comes from BPMs on the Nanotomography straight section (it cannot be checked with an XBPM yet)



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Beam Quality Criteria for Beam Stability at SOLEIL

- We recently defined the Beamline useful beam time : It is the <u>Percentage of Beam Time that fulfills the Beamline</u> <u>requirements</u>.
- \Leftrightarrow A realistic number must be > 90%
- \Leftrightarrow All source points of the ring are archived.
- In this way, we can estimate the <u>Useful Beam Time</u> for <u>future</u> <u>Beamline</u> by checking the time their requirements would have been met in 2012, for example.
- Then, we discuss again the requirements and/or the possible machine improvements, an/or possible beamline improvements.



SOLEIL Most Critical Beamline Stability Requirements (updated 22/04/2013)						
paramètre ↓	PX1	PX2	Anatomix	Nano scopium	Tightest wrt Beam size	
Temps acq.	5 mn	de 10 à 30 mn (90% et 10% des utilisations)	10mn (pos. & ang); 6h (σ, σ')	8 hours		
Position H	35 µm rms	30 µm rms	\pm 12 μ m	$\pm 5 \ \mu m$	~ o _x /125 *	
Angle H	3 µrad rms	4 µrad rms	$\pm 4 \mu rad$	$\pm 5 \mu rad$	~σ' _x /15 *	
Position V	1 μm rms	1.3 µm rms	$\pm 1 \ \mu m$	$\pm 1.5 \mu m$	~\sigma_z/25 *	
Angle V	$\pm 1.5 \mu rad$	1 µrad rms	±1 μrad	\pm 1.5 µrad	σ' _z /14 *	
Taille	/	/	± 5% en 6h***	± 2% (besoin info pour acquisitions « stop and go »)		
Divergence	/	± 10%	± 5% en 6h (99% manips)	± 2%		
% de faisceau utile**	100%	99%	95%	?		

 $* \sigma$ is the beam size and σ ' the divergence of the <u>PHOTON Beam</u> at its source point

and the highest user energy. Equivalence: $\pm 2.5 \ \mu m \ (or \ \mu rad) \approx 1 \ \mu m \ rms \ (or \ \mu rad \ rms)$ ** mesured on archived data of week 2012/37

*** tolerates 1% of acquisitions out of tolérances in a 6h lo of data.



USR Orbit Feedback Systems

\Leftrightarrow Probably similar to existing systems

- Bandwidth extension to 500 Hz or more would supress better the 50Hz spectrum lines of the mains an its harmonics (60 Hz in Americas)
- Vacuum chamber space with thin stainless steel walls or ceramic gaps need to be reserved for fast correctors
- If a square correction matrix is not possible, the correction algorithm should favor the few beamlines with tightest stability requirements. This is done with different « weights » depending on the BPM.
- Beam Instrumentation and feedback systems should go to the Beamlines too.



SOLEIL Feedback Characteristics

Parameters (H,V)	SOFB	FOFB	
BPM #	122, 122	122, 122	
Corrector #	57, 57	50, 50 (in straight	
	(in arcs)	sections)	
Sing. Value #	57, 57	46, 47	
Corrector maximum strength	1.0, 0.7 mrad	28, 23 μrad	
Correction rate	0.1 Hz	10 kHz	
Bandwidth	0-0.05 Hz	0-200 Hz	
Efficiency	IDs and arcs	Mostly IDs	



SIRIUS BPM electronics specifications - Last update: 2013-March-22

BPM system specifications	Fast acquisition or slower (users operation)	Turn by turn (machine studies)	Single-Pass (commisssioning)	comments
absolute accuracy wrt alignment references	Does not depend on the BPM system	N/A	< 0.5 mm before BBA	BPM mechanical alignment references & BBA & BCD & BPD
Resolution (rms position fluctuations 0.1 to 1000 Hz)	<mark>< 0.14</mark> μm	< 3 µm	N/A	Beam current > 50 mA, multi bunch mode, 3/4 filling pattern
Resolution for 1st turns and single- pass	N/A	N/A	< 0.5 mm	200 ns bunch train, 1.5 nC total charge
1 hour stability	< 0.14 µm	N/A	N/A	sigma/10, centered and 0.5 mm off- center beam
1 week stability	< 5 µm	N/A	N/A	Minimum time between 2 BL realignments, centered and 0.5 mm off- center beam
Beam Current Dependence before top-up (BCD)	< 1 µm	N/A	N/A	Centered or 0.5 mm off-center beam & 30% beam current decrease; 50 mA < Ib< 200 mA
Beam Current Dependence with top- up (BCD)	< 0.14 µm	N/A	N/A	Centered and 0.5 mm off-center beam; 50 mA <lb<500 ma<="" th=""></lb<500>
BCD for BBA from 20 to 500 mA	10 to 15 µm	N/A	N/A	BBA current = 20 mA ?; defined by vacuum group (crotch absorber?)
Bunch Pattern Dependence (BPD)	< 5 µm	N/A	N/A	Minimum time between bunch pattern changes = 1 week
H to V coupling (DY for DX=1mm)	< 10 µm	< 10 µm	N/A	BPM block + electronics

Comment 1: all the mentioned beam offsets are wrt the BPM electrical offset



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Simulations for SIRIUS Fast Orbit Feedback (Courtesy Daniel Tavares)

Closed-loop specifications:

- PI controller
- Stability: phase margin $> 50^{\circ}$
- Peak disturbance amplification < 5 dB (\approx factor 1.8)

Fixed parameters:

- Vacuum chamber bandwidth (7.4 kHz and 14.8 kHz)
- Orbit correction calculation latency (1 FOFB period)
- BPM digital filter latency (3 FOFB periods)





Tentative specifications for SIRIUS (D. Tavares)

• Vacuum chamber bandwidth?

Tentative answer: 7.4 kHz (50 µm copper coating on ceramic chamber)

- Power + magnets bandwidth?
- Data distribution network delays?
- Orbit correction calculation algorithm period?

Tentative answer: 5 µs (full parallel Matrix multiplication + PI on FPGA)

• BPM filters group delay?

Answer: 30 µs @ 100 kHz update rate

• FOFB sampling rate?

Tentative answer: 100 kHz



Conclusions

- We are all very proud to have contributed to the BPM electronics that is presently the state of the art.
- People from labs and from industry showed they can team-up and design a product that benefits the whole community.
- \Leftrightarrow Trust in each others has been the key for success.
- The present performance is not far from what is needed in the next one or two decades.
 - > Stability should reach ~ 0.2 to 0.1 μ m in one hour
 - Reduced delay for wider FOFB bandwidth can be achieved with higher switching electrode rates (100 kHz at SIRIUS).
 - The reliability is a very important parameter. The whole system MTBF including FOFB should be > 3 months and each failure quickly fixed.

